

## Normally – OFF Silicon Carbide Junction Transistor

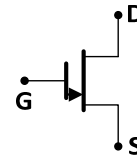
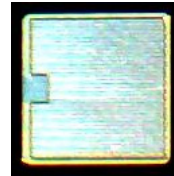
$V_{DS}$	=	600 V
$R_{DS(ON)}$	=	65 mΩ
$I_D$ ( $T_C = 25^\circ\text{C}$ )	=	45 A
$h_{FE}(T_C = 25^\circ\text{C})$	=	110

### Features

- 250°C maximum operating temperature
- Gate Oxide Free SiC switch
- Exceptional Safe Operating Area
- Excellent Gain Linearity
- Temperature Independent Switching Performance
- Low Output Capacitance
- Positive Temperature Co-efficient of  $R_{DS,ON}$
- Suitable for connecting an anti-parallel diode

### Advantages

- Compatible with Si MOSFET/IGBT gate-drivers
- > 20 μs Short-Withstand Capability
- Lowest-in-class Conduction Losses
- High Circuit Efficiency
- Minimal Input Signal Distortion
- High Amplifier Bandwidth



### Applications

- Down Hole Oil Drilling, Geothermal Instrumentation
- Hybrid Electric Vehicles (HEV)
- Solar Inverters
- Switched-Mode Power Supply (SMPS)
- Power Factor Correction (PFC)
- Induction Heating
- Uninterruptible Power Supply (UPS)
- Motor Drives

## Electrical Specifications

### Absolute Maximum Ratings

Parameter	Symbol	Conditions	Values	Unit
Drain – Source Voltage	$V_{DS}$	$V_{GS} = 0\text{ V}$	600	V
Continuous Drain Current	$I_D$	$T_{VJ} < 250^\circ\text{C}$	20	A
Gate Peak Current	$I_{GM}$		10	A
Turn-Off Safe Operating Area	RBSOA	$T_{VJ} = 250^\circ\text{C}$ , $I_G = 1\text{ A}$ , Clamped Inductive Load	$I_{D,max} = 20$ @ $V_{DS} \leq V_{DSmax}$	A
Short Circuit Safe Operating Area	SCSOA	$T_{VJ} = 250^\circ\text{C}$ , $I_G = 1\text{ A}$ , $V_{DS} = 400\text{ V}$ , Non Repetitive	20	μs
Reverse Gate – Source Voltage	$V_{GS}$		30	V
Reverse Drain – Source Voltage	$V_{DS}$		40	V
Operating and Storage Temperature	$T_J, T_{stg}$		-55 to 250	°C

### Electrical Characteristics

Parameter	Symbol	Conditions	Values			Unit
			min.	typ.	max.	
<b>On Characteristics</b>						
Drain – Source On Resistance	$R_{DS(ON)}$	$I_D = 20\text{ A}$ , $I_G = 400\text{ mA}$ , $T_J = 25^\circ\text{C}$		65		mΩ
		$I_D = 20\text{ A}$ , $I_G = 500\text{ mA}$ , $T_J = 125^\circ\text{C}$		90		
		$I_D = 20\text{ A}$ , $I_G = 1000\text{ mA}$ , $T_J = 175^\circ\text{C}$		110		
		$I_D = 20\text{ A}$ , $I_G = 1000\text{ mA}$ , $T_J = 250^\circ\text{C}$		165		
Gate Forward Voltage	$V_{GS(FWD)}$	$I_G = 1000\text{ mA}$ , $T_J = 25^\circ\text{C}$		3.0		V
		$I_G = 1000\text{ mA}$ , $T_J = 250^\circ\text{C}$		2.7		
DC Current Gain	$h_{FE}$	$V_{DS} = 5\text{ V}$ , $I_D = 20\text{ A}$ , $T_J = 25^\circ\text{C}$		110		
		$V_{DS} = 5\text{ V}$ , $I_D = 20\text{ A}$ , $T_J = 125^\circ\text{C}$		78		
		$V_{DS} = 5\text{ V}$ , $I_D = 20\text{ A}$ , $T_J = 175^\circ\text{C}$		73		
		$V_{DS} = 5\text{ V}$ , $I_D = 20\text{ A}$ , $T_J = 250^\circ\text{C}$		69		

### Off Characteristics

Drain Leakage Current	$I_{DSS}$	$V_R = 600\text{ V}$ , $V_{GS} = 0\text{ V}$ , $T_J = 25^\circ\text{C}$	10		μA
Gate – Source Leakage Current	$I_{GSS}$	$V_{GS} = -20\text{ V}$ , $T_J = 25^\circ\text{C}$	20		nA

### Capacitance Characteristics

Input Capacitance	$C_{iss}$	$V_{GS} = 0\text{ V}$ , $V_D = 100\text{ V}$ , $f = 1\text{ MHz}$	2500		pF
Reverse Transfer/Output Capacitance	$C_{rss}/C_{oss}$	$V_D = 100\text{ V}$ , $f = 1\text{ MHz}$	160		pF

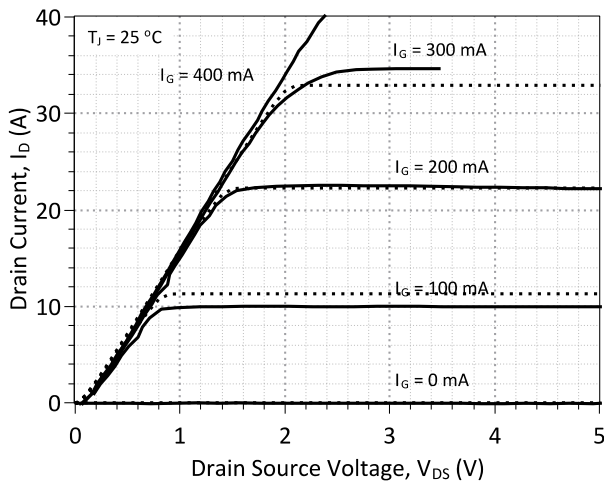


Figure 1: Typical Output Characteristics at 25 °C

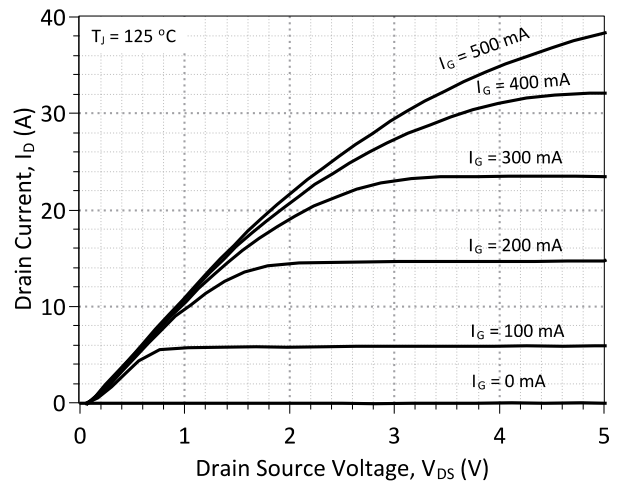


Figure 2: Typical Output Characteristics at 125 °C

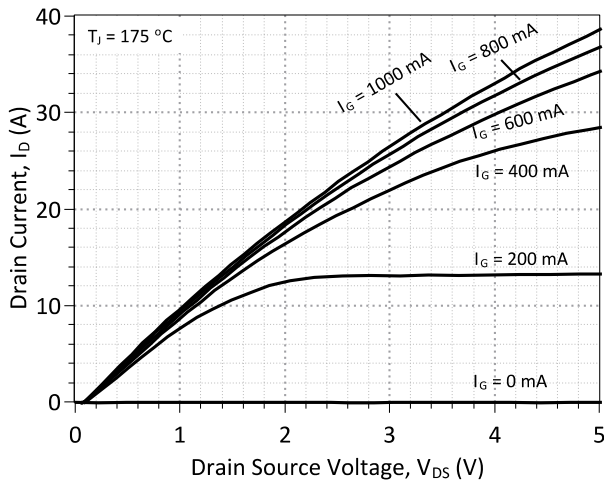


Figure 3: Typical Output Characteristics at 175 °C

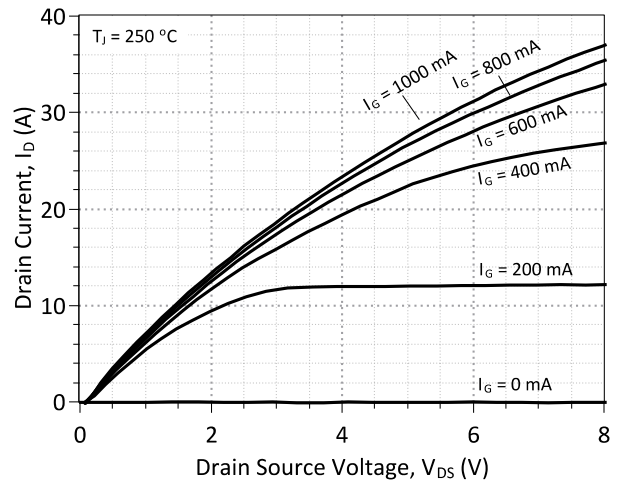


Figure 4: Typical Output Characteristics at 250 °C

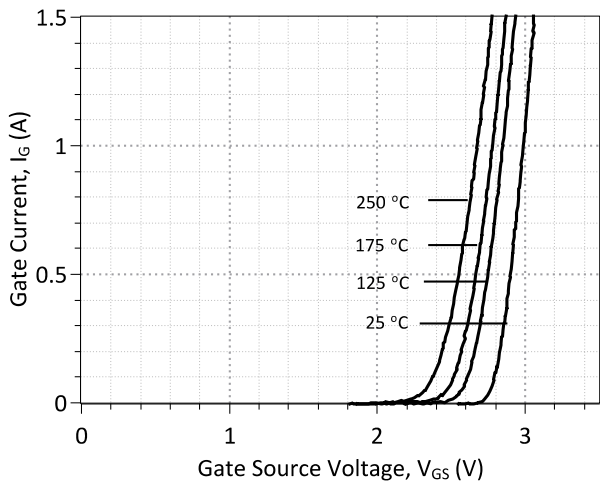


Figure 5: Typical Gate Source I-V Characteristics vs. Temperature

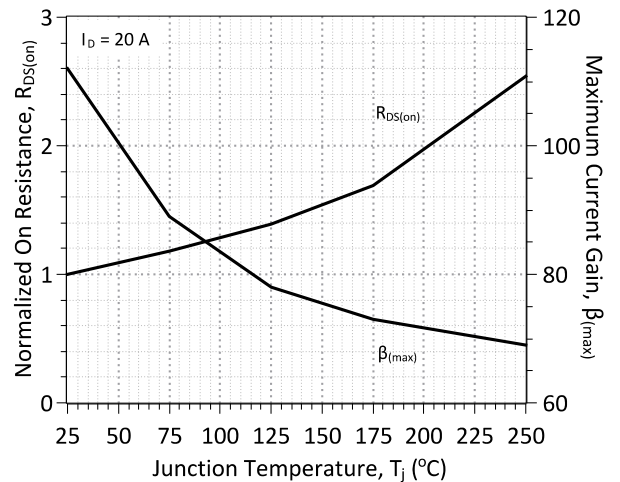


Figure 4: Normalized On-Resistance and Current Gain vs. Temperature

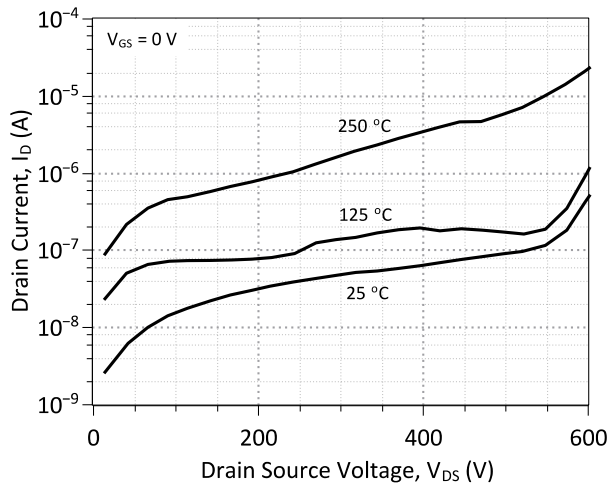


Figure 7: Typical Blocking Characteristics

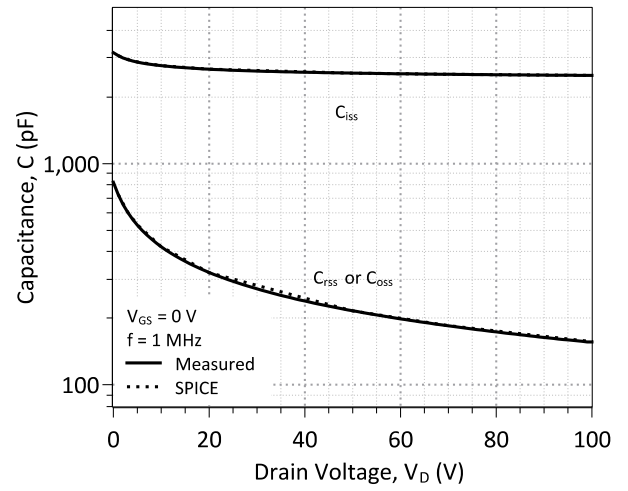


Figure 8: Capacitance Characteristics

### Gate Drive Theory of Operation

The SJT transistor is a current controlled transistor which requires a positive gate current for turn-on as well as to remain in on-state. An ideal gate current waveform for ultra-fast switching of the SJT, while maintaining low gate drive losses, is shown in Figure 9.

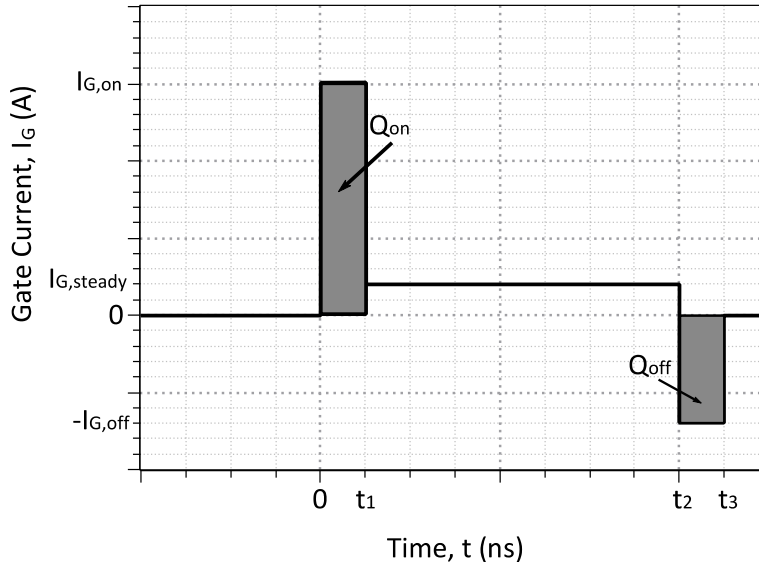


Figure 9: Idealized Gate Current Waveform

#### Gate Currents, $I_{G,pk}/-I_{G,pk}$ and Voltages during Turn-On and Turn-Off

An SJT is rapidly switched from its blocking state to on-state, when the necessary gate charge,  $Q_G$ , for turn-on is supplied by a burst of high gate current,  $I_{G,on}$ , until the gate-source capacitance,  $C_{GS}$ , and gate-drain capacitance,  $C_{GD}$ , are fully charged.

$$I_{G,on} * t_1 \geq Q_{gs} + Q_{gd}$$

The  $I_{G,on}$  pulse should ideally terminate, when the drain voltage falls to its on-state value, in order to avoid unnecessary drive losses during the steady on-state. In practice, the rise time of the  $I_{G,on}$  pulse is affected by the parasitic inductances,  $L_{par}$  in the package and drive circuit. A voltage developed across the parasitic inductance in the source path,  $L_s$ , can de-bias the gate-source junction, when high drain currents begin to flow through the device. The applied gate voltage should be maintained high enough, above the  $V_{GS,ON}$  level to counter these effects.

A high negative peak current,  $-I_{G,off}$  is recommended at the start of the turn-off transition, in order to rapidly sweep out the injected carriers from the gate, and achieve rapid turn-off. While satisfactory turn off can be achieved with  $V_{GS} = 0$  V, a negative gate voltage  $V_{GS}$  may be used in order to speed up the turn-off transition.

#### Steady On-State

After the device is turned on,  $I_G$  may be advantageously lowered to  $I_{G,steady}$  for reducing unnecessary gate drive losses. The  $I_{G,steady}$  is determined by noting the DC current gain,  $h_{FE}$ , of the device

The desired  $I_{G,steady}$  is determined by the peak device junction temperature  $T_J$  during operation, drain current  $I_D$ , DC current gain  $h_{FE}$ , and a 50 % safety margin to ensure operating the device in the saturation region with low on-state voltage drop by the equation:

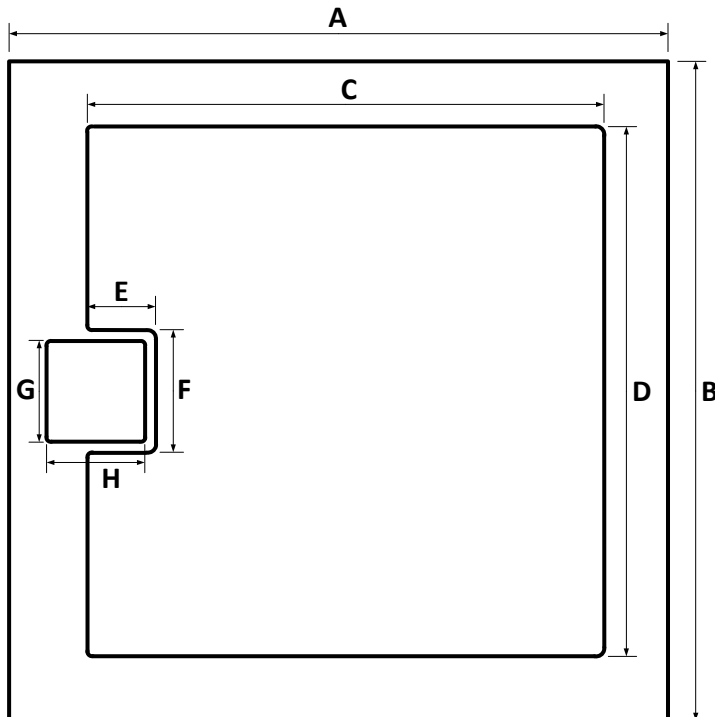
$$I_{G,steady} \approx \frac{I_D}{h_{FE}(T, I_D)} * 1.5$$

**Mechanical Specifications**

**Mechanical Parameters**

Raster Size	2.85 x 2.85	mm <sup>2</sup>	112 x 112	mil <sup>2</sup>
Area total / active	8.12/6.60	mm <sup>2</sup>	12544/10237	mil <sup>2</sup>
Thickness	360	μm	14	mil
Wafer Size	100	mm	3937	mil
Flat Position	0	deg	0	deg
Passivation frontside	Polyimide			
Pad Metal (Anode)	4000 nm Al			
Backside Metal (Cathode)	400 nm Ni + 200 nm Au -system			
Die Bond	Electrically conductive glue or solder			
Wire Bond	Al ≤ 10 mil (Source) Al ≤ 3 mil (Gate)			
Reject ink dot size	Φ ≥ 0.3 mm			
Recommended storage environment	Store in original container, in dry nitrogen, < 6 months at an ambient temperature of 23 °C			

**Chip Dimensions:**



		mm	mil
DIE	A	2.85	112
	B	2.85	112
SOURCE WIREBONDABLE	C	2.23	88
	D	2.29	90
	E	0.30	12
	F	0.53	21
GATE WIREBONDABLE	G	0.44	17
	H	0.43	17

**Revision History**

Date	Revision	Comments	Supersedes
2014/08/26	3	Updated Electrical Characteristics	
2014/04/29	2	Updated Electrical Characteristics	
2014/02/27	1	Updated Electrical Characteristics	
2013/12/04	0	Initial release	

## Published by

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43670 Trade Center Place Suite 155  
Dulles, VA 20166

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## SPICE Model Parameters

This is a secure document. Please copy this code from the SPICE model PDF file on our website ([http://www.genesicsemi.com/images/hit\\_sic/baredie/sjt/GA20JT06-CAL\\_SPICE.pdf](http://www.genesicsemi.com/images/hit_sic/baredie/sjt/GA20JT06-CAL_SPICE.pdf)) into LTSPICE (version 4) software for simulation of the GA20JT06-CAL.

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*      MODEL OF GeneSiC Semiconductor Inc.
*
*      $Revision:   1.1           $
*      $Date:      27-FEB-2014   $
*
*      GeneSiC Semiconductor Inc.
*      43670 Trade Center Place Ste. 155
*      Dulles, VA 20166
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*      Models accurate up to 2 times rated drain current.
*
.model GA20JT06 NPN
+ IS      5.00E-47
+ ISE     1.26E-28
+ EG      3.23
+ BF      114
+ BR      0.55
+ IKF     700
+ NF      1
+ NE      2
+ RB      0.26
+ RE      0.01
+ RC      0.045
+ CJC     8.2281E-10
+ VJC     3.311262797257
+ MJC     0.4811772789929
+ CJE     2.33957E-9
+ VJE     2.91486059646
+ MJE     0.4821112143335
+ XTI     3
+ XTB     -1.2
+ TRC1    6.20E-03
+ VCEO    600
+ ICRATING 20
+ MFG     GeneSiC_Semiconductor
*
* End of GA20JT06-CAL SPICE Model
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